



Technical Data Sheet

ACS Material Monolayer MoSe₂ on SiO₂

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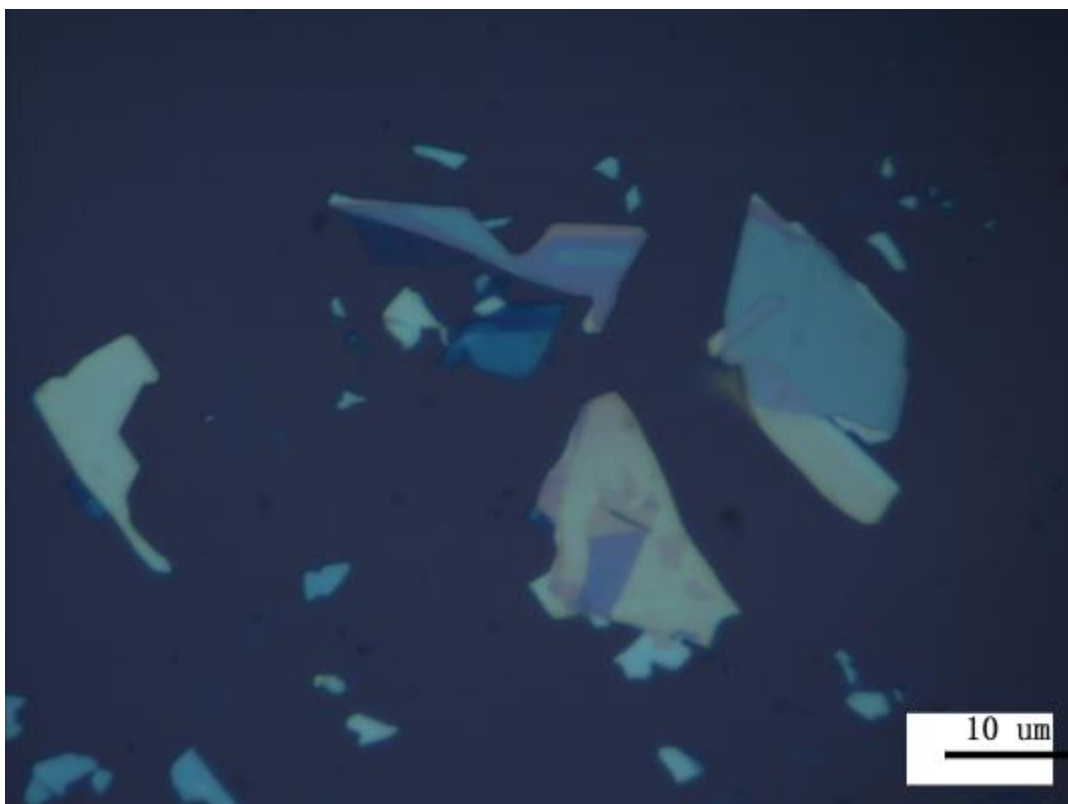
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1. Preparation Method

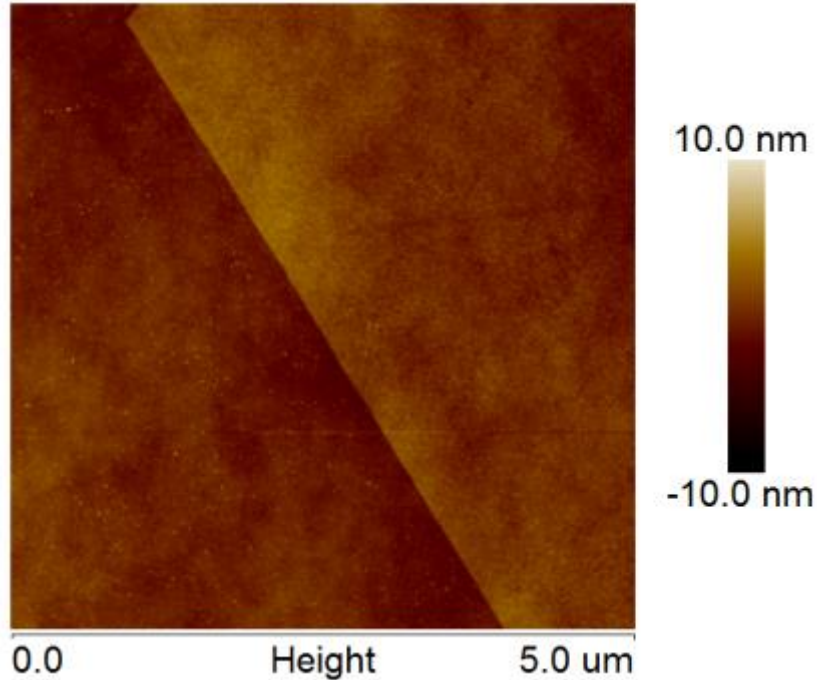
Mechanical exfoliation method

2. Characterizations

Substrate:	SiO ₂
Substrate size:	10 mm x 10 mm
Monolayer MoSe ₂ Area:	>10 μm ²



Typical Image of ACS Material Monolayer MoSe₂ on SiO₂ substrate



Typical AFM Image of ACS Material Monolayer MoSe₂ on SiO₂ substrate

3. Application Fields

An excellent device material for studying the number of layers and fluorescence effects.

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